

IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A transparent substrate ~~[[ (6) ]]~~, comprising on at least one of its faces an antireflection coating, ~~particularly at normal incidence made of a multilayer (A) of thin layers made of dielectrical material with alternatively high and low refractive indexes, characterized in that the multilayer comprises~~ comprising, in succession:

a high-index first layer (1) comprising a doped mixed oxide of Sn and Zn ~~doped or not doped~~, with a refractive index  $n_1$  of between 1.8 and 2.2 and geometrical thickness  $e_1$  of between 5 and 50 nm,

a low-index second layer (2) comprising  $\text{SiO}_2$ , with a refractive index  $n_2$  of between 1.35 and 1.65 and a geometrical thickness  $e_2$  of between 5 and 50 nm,

a high-index third layer (3) comprising a doped mixed oxide of Sn and Zn doped or not doped, with a refractive index  $n_3$  of between 1.8 and 2.2 and a geometrical thickness  $e_3$  of between 40 and 150 nm, and

a low-index depth fourth layer (4) comprising  $\text{SiO}_2$ , with a refractive index  $n_4$  of between 1.35 and 1.65 and a geometrical thickness  $e_4$  of between 40 and 120 nm,

wherein light reflection on the side on which the substrate is equipped with the multilayer is lowered by a minimum amount of 3 or 4% at a normal angle of incidence.

Claim 2 (Previously Presented): The substrate (6) as claimed in claim 1, wherein  $n_1$  and/or  $n_3$  are between 1.85 and 2.15.

Claim 3 (Cancelled).

Claim 4 (Previously Presented): The substrate (6) as claimed in claim 1, wherein  $e_1$  is between 5 and 50 nm.

Claim 5 (Previously Presented): The substrate (6) as claimed in claim 1, wherein  $e_2$  is between 5 and 50 nm.

Claim 6 (Previously Presented): The substrate (6) as claimed in claim 1, wherein  $e_3$  is between 45 and 80 nm.

Claim 7 (Previously Presented): The substrate (6) as claimed in claim 1, wherein  $e_4$  is between 45 and 110 nm.

Claim 8 (Currently Amended): A substrate (6) as claimed in Claim 1 wherein the high-index first layer (1) and the low-index second layer (2) are replaced by an intermediate-index single layer (5)  $e_5$  of between 1.65 and 1.80 ~~and preferably having an optical thickness  $e_{opt5}$  of between 50 and 140 nm, preferably between 85 and 120 nm.~~

Claim 9 (Previously Presented): The substrate (6) as claimed in claim 8, wherein the intermediate-index layer (5) is based on a mixture of silicon oxide and at least one metal oxide chosen from tin oxide, zinc oxide, titanium oxide or is based on a silicon oxynitride or oxycarbide and/or aluminum oxynitride.

Claims 10-12 (Cancelled)

Claim 13 (Previously Presented): The substrate as claimed in claim 1, wherein said substrate is made of clear or bulk-tinted glass.

Claim 14 (Cancelled).

Claim 15 (Previously Presented): The substrate as claimed in claim 1, wherein the colorimetry of its light reflection on the side on which it is equipped with the multilayer made up of thin layers is such that the corresponding  $b^*$  value in the ( $L^*$ ,  $a^*$ ,  $b^*$ ) colorimetry system is negative, at a normal angle of incidence.

Claims 16 -18 (Cancelled).

Claim 19 (Currently Amended): The substrate  $[(6)]$  as claimed in claim 1, wherein it is equipped on one of its faces with the anti-reflection multilayer and, on its other face, either with no antireflection multilayer or also with an antireflection multilayer, or with another type of antireflection coating, or with a coating having another functionality of solar protection, low emissivity, antifouling, antifogging, antirain or heating.

Claim 20 (Previously Presented): The substrate as claimed in claim 19, wherein the other type of antireflection coating is chosen from the following coatings:

a single layer with a low index, lower than 1.60 or 1.50,

a single layer the refractive index of which varies through its thickness,

a two-layer multilayer comprising, in succession, a layer with a high index of at least 1.8, particularly tin oxide, zinc oxide, zirconium oxide, titanium oxide, silicon or aluminum nitride, followed by a layer with a low index, below 1.65,

three-layer multilayer comprising, in succession, a layer of medium index of between 1.65 and 1.8 of the silicon and/or aluminum oxycarbide or oxynitride type, a layer with a high index above 1.9 of the  $\text{SnO}_2$ ,  $\text{TiO}_2$  type, a layer with a low index less than 1.65 of the mixed Si-Al oxide or silicon oxide type antifouling coating.

Claim 21 (Previously Presented): A multiple glazed unit, comprising at least two substrates as claimed in claim 1, wherein the two glass substrates are combined using a sheet of thermoplastic, the substrate being equipped, on the opposite side to the assembly, with the antireflection multilayer and the substrate being equipped, on the opposite side to the assembly, with either no antireflection coating or also an antireflection coating, or with another type of antireflection coating, or with a coating having another functionality of the solar protection, low emissivity, antifouling, antifogging, antirain or heating type, it also being possible for said coating with another functionality to be located on one of the faces of the substrates that face toward the thermoplastic sheet used for assembly.

Claim 22 (Withdrawn): A method for producing the glazing as claimed in claim 21, comprising depositing the antireflection multilayer or multilayers by cathode sputtering and optionally depositing an antireflection coating by a sol-gel technique, a pyrolysis technique of the CVD, or plasma CVD type, by cathode sputtering or by corona discharge.

Claim 23 (Previously Presented): A glazed product produced by the glazing method as claimed in claim 21 wherein said glazed product is an interior or exterior glazing for buildings, a display cabinet, a counter in stores, that may be curved, an anti-dazzle computer screen, or a glass furniture.